

b) Amendment to the Claims

Please cancel claims 14-25 without prejudice or disclaimer of the subject matter therein. Please amend claim 12 as follows. The status of all the claims is listed below.

Claims 1. - 11. (Cancelled)

12. (Currently Amended) A plasma treatment apparatus comprising:
a plurality of reactors each having an evacuable inside interior
where at least one treatment substrate is set in, and having impedances different from each
other;

a high-frequency power supply means for supplying high-frequency
power into each reactor having been inside internally-evacuated, to cause glow discharge to
take place in the reactor, wherein each of the reactors and the high-frequency power supply
means are provided separably;

a plurality of an impedance regulation means provided
correspondingly to the impedances of each of the reactors in order to regulate impedances
impedance spaced in on the side of each reactor and in on the side of the high-frequency
power supply means; and

a moving means for moving the reactors.

13. (New) The plasma treatment apparatus of claim 12, wherein the substrate is a substrate for an electrophotographic photosensitive member.

14. - 25. (Cancelled)